Application No. 10/627,702 Amendment under 37 C.F.R. §1.312 Response to Notice of Allowance dated December 19, 2005

IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A pattern inspection apparatus comprising:

a stage on which a plate to be inspected including a pattern formed on the plate is laid;

a light source which irradiates the plate to be inspected with light;

a photoelectric device which photoelectrically converts the optical image of the

pattern;

a detected pattern data generator which generates detected pattern data regarding the

pattern based on a signal obtained by the photoelectric device;

a reference pattern data generator which generates reference pattern data from

designed data regarding the pattern, or stores the detected pattern data obtained by the

photoelectric device;

a comparator which compares the detected pattern data with the reference pattern

data;

a light intensity sensor which detects a light intensity of the light source;

a barometric pressure sensor which detects a barometric pressure in the pattern

inspection apparatus;

a status detector which senses that at least one of the light intensity and the barometric

pressure deviates from a predetermined range;

a data memory which stores the detected pattern data and the reference pattern data

corresponding to the detected pattern data at a point of time when the status detector detects

that the at least one of the light intensity and the barometric pressure deviate from the

predetermined ranges are stored in synchronization with position data on the plate to be

inspected and a detected value of the at least one of the light intensity and the barometric

pressure deviating from the predetermined range;

2

an output device which outputs the detected pattern data, the reference pattern data, and the detected value of the at least one of the light intensity and the barometric pressure stored in the data memory;

a signal intensity profile analysis part which analyzes a signal intensity profile of the detected pattern data at an abnormal status time;

a re-inspection control part which re-inspects at least a part on the plate to be inspected based on an analysis result of the signal intensity profile analysis part; and an abnormal status notification part which notifies the analysis result,

wherein the signal intensity profile analysis part compares signal gradients of horizontal and vertical direction components of a pattern edge part of the detected pattern data with a first predetermined standard value, and an intensity and fluctuation of a signal of a pattern bright part with a second predetermined standard value.

Claim 2 (Original): The pattern inspection apparatus according to claim 1, further comprising a focus sensor which detects a focus abnormal status of the illumination and imaging optics.

Claim 3 (Original): The pattern inspection apparatus according to claim 1, further comprising a vibration sensor which detects vibration of the stage for the plate to be inspected.

Claims 4 and 5 (Canceled).

Claim 6 (Previously Presented): The pattern inspection apparatus according to claim 1, wherein the signal intensity profile analysis part compares the signal gradients of the

Application No. 10/627,702

Amendment under 37 C.F.R. §1.312

Response to Notice of Allowance dated December 19, 2005

horizontal and vertical directions with respect to the pattern edge part of the detected pattern

data, and judges that vibration of the stage is generated, when a difference between the signal

gradients is not less than the first predetermined standard value.

Claim 7 (Previously Presented): The pattern inspection apparatus according to claim

1, wherein the signal intensity profile analysis part compares the signal gradients of different

diagonal directions of a pattern corner part of the detected pattern data, and judges that

vibration of the stage is generated, when a difference between the signal gradients is not less

than the predetermined standard value.

Claim 8 (Previously Presented): The pattern inspection apparatus according to claim

1, wherein the comparator stores the detected pattern data and the reference pattern data

corresponding to the detected pattern data by the predetermined number of times, when the

same abnormal status is detected by the predetermined number of times in a first

predetermined time, and stops storage into the data memory with respect to the same

abnormal status until a second predetermined time elapses.

Claims 9-17 (Canceled).

4